G⁰ PC Installation and Beam Studies

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Presentation Outline

- Pockels Cell Installation (Injector)
- Electron Beam Studies

Pockels Cell Installation (Injector) March 21-22, 2006

- What did we accomplish?
 - Characterized Intensity Asymmetry (IA) Cell:
 λ/4, 14°
 - Measured dependence of intensity loss on waveplate angle: -1.45%/° (20% at 14°)
 - Measured dependence of intensity asymmetry on voltage: -17.75 ppm/V
 - Aligned Pockels Cell (PC)
 - Degree of linear polarization = 3.2%
 - Degree of circular polarization = 99.9%
 - Minimized x and y position differences.

Pockels Cell Installation Results March 21-22, 2006

Steering (LP OUT)	IHWP IN	IHWP OUT	Goal
Δχ	0.024 ± 0.023 µm	0.10 ± 0.014 µm	< 0.1 μm
Δy	0.37 ± 0.019 μm	-0.21 ± 0.019 µm	< 0.1 μm
Δcharge	41.72 ± 0.63 ppm	-29.33 ± 0.62 ppm	

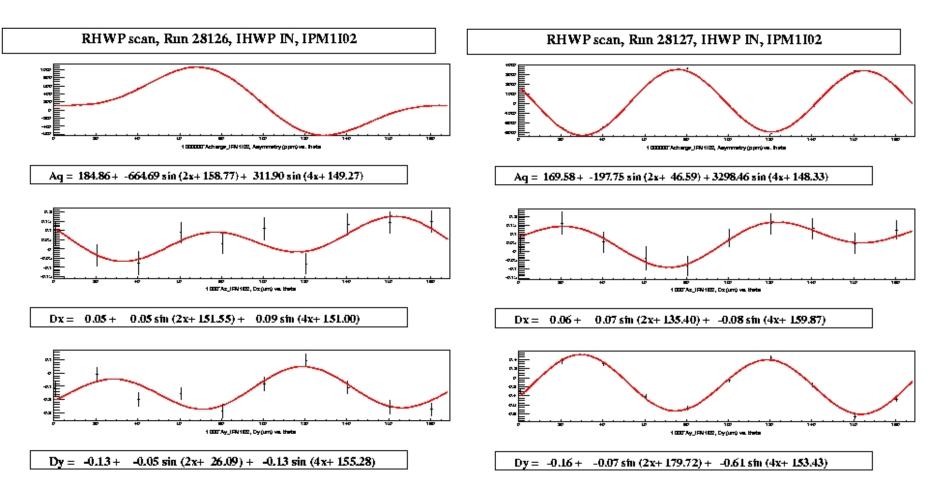
Birefringence (LP IN)	IHWP IN	IHWP OUT	Goal
Δχ	5.71 ± 0.015 µm	-2.96 ± 0.015 μm	< 6 µm
Δy	-5.12 ± 0.023 μm	1.71 ± 0.025 µm	< 6 µm
Δcharge	-1.02E4 ± 54 ppm	1.31E4 ± 52 ppm	

Electrical Pickup	
Δχ	0.035 ± 0.014 μm
Δy	0.013 ± 0.012 μm
Δcharge	1.76 ± 0.56 ppm

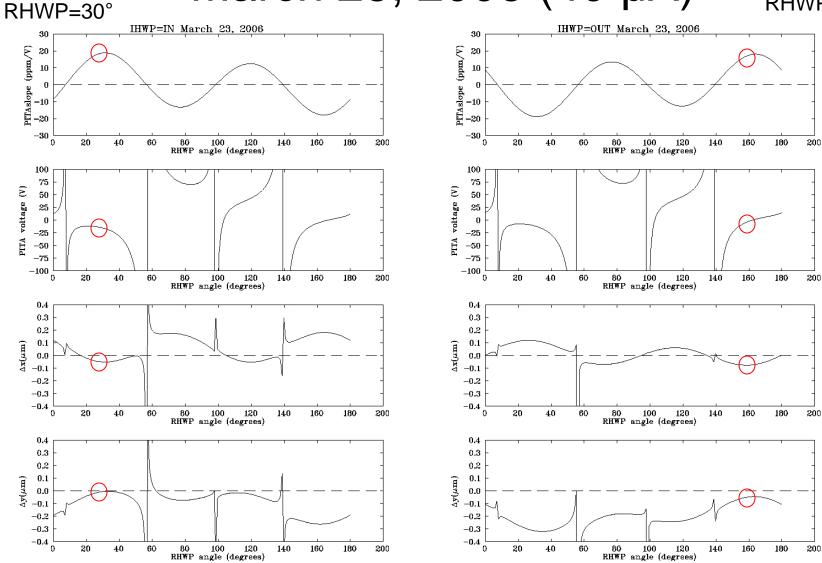
w/ photocathode 3X larger in injector w/ photocathode 20X smaller in injector

Injector	Наррех
Δχ	< 0.3 μm
Δy	< 0.3 μm
Δcharge	

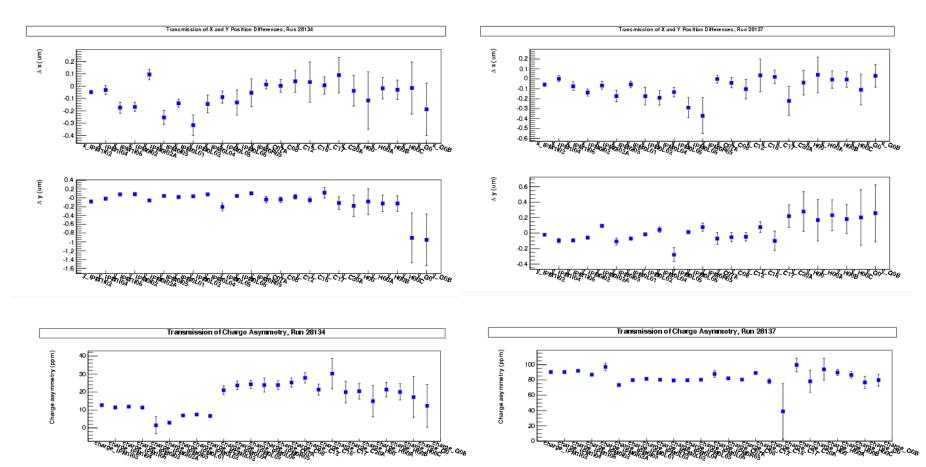
PITA=0 PITA=-192



RHWP=160°

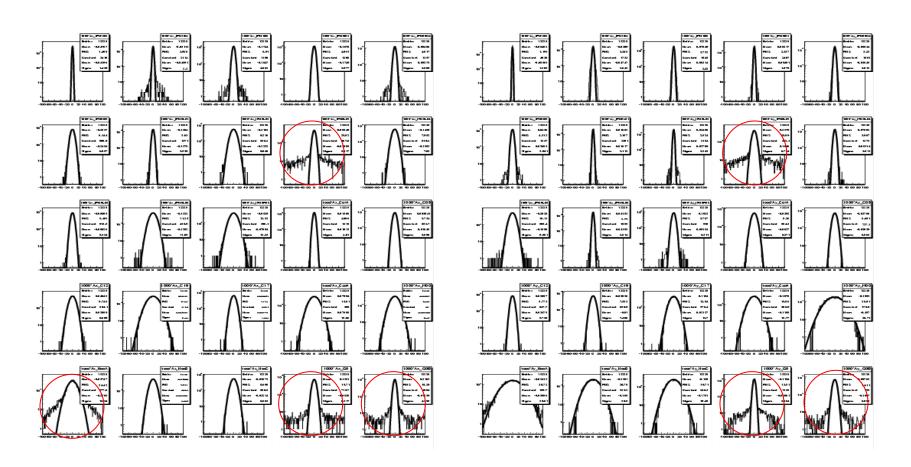


IHWP = OUT RHWP = 160° 17 ppm/V IHWP = IN RHWP = 30° 18 ppm/V



X BPM Position Differences

Y BPM Position Differences



Summary

- In the 100 keV region of the injector, all of the position differences are less than 0.3 um.
- Charge asymmetry can easily be controlled with the size of the PITA slope.